

L Number	Hits	Search Text	DB	Time stamp
1	540463	resist or pr or photoresist	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/16 21:05
2	38103	reflow\$4	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/16 20:02
3	704	(resist or pr or photoresist) near2 reflow\$4	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/16 20:02
4	379877	polyacrylic or polyvinyl or polyvinylacetal or polyvinylalcohol or polyethyleneimine or polyethyleneoxide or styrene near2 maleic or methylvinyleher or polyallylamine	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/16 20:06
5	5502	(layer or film or cover\$4) adj2 (over or top or cover\$4) adj2 (resist or pr or photoresist)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/16 22:01
6	12	((layer or film or cover\$4) adj2 (over or top or cover\$4) adj2 (resist or pr or photoresist)) same ((resist or pr or photoresist) near2 reflow\$4)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/16 20:11
7	6	((layer or film or cover\$4) adj2 (over or top or cover\$4) adj2 (resist or pr or photoresist)) same ((resist or pr or photoresist) near2 reflow\$4)) and (@ad < "20020826")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/16 20:23
8	2300524	polyimide or polyacetal or polybutylene adj terephthalate or polyethylene adj trephthalate or syndiotactic adj polystyree or (polyphenylene or poly adj phenylene) adj slufide or polyetherether adj ketone or crystal adj polymer or fluorine adj resin or polyehtermitrile or polycarbonate or poly adj pheynyleneether or polysulfone or polyethersulfone or polyacrylater or polyalylate or polyamide-imide or resin or polyester or polyurethane	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/16 20:19
9	0	(polyacrylic or polyvinyl or polyvinylacetal or polyvinylalcohol or polyethyleneimine or polyethyleneoxide or styrene near2 maleic or methylvinyleher or polyallylamine) adj2 (over or top or cover\$4) adj2 (resist or pr or photoresist)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/16 20:19
10	94	(polyimide or polyacetal or polybutylene adj terephthalate or polyethylene adj trephthalate or syndiotactic adj polystyree or (polyphenylene or poly adj phenylene) adj slufide or polyetherether adj ketone or crystal adj polymer or fluorine adj resin or polyehtermitrile or polycarbonate or poly adj pheynyleneether or polysulfone or polyethersulfone or polyacrylater or polyalylate or polyamide-imide or resin or polyester or polyurethane) adj2 (over or top or cover\$4) adj2 (resist or pr or photoresist)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/16 20:20
11	0	((polyimide or polyacetal or polybutylene adj terephthalate or polyethylene adj trephthalate or syndiotactic adj polystyree or (polyphenylene or poly adj phenylene) adj slufide or polyetherether adj ketone or crystal adj polymer or fluorine adj resin or polyehtermitrile or polycarbonate or poly adj pheynyleneether or polysulfone or polyethersulfone or polyacrylater or polyalylate or polyamide-imide or resin or polyester or polyurethane) adj2 (over or top or cover\$4) adj2 (resist or pr or photoresist)) and ((resist or pr or photoresist) near2 reflow\$4)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/16 20:21

12	109	((polyacrylic or polyvinyl or polyvinylacetal or polyvinylalcohol or polyethyleneimine or polyethyleneoxide or styrene near2 maleic or methylvinyleher or polyallylamine) or (polyimide or polyacetal or polybutylene adj terephthalate or polyethylne adj trephthalate or syndiotactic adj polystyree or (polyphenylene or poly adj phenylene) adj slufide or polyetherether adj ketone or crystal adj polymer or fluorine adj resin or polyehtermitrile or polycarbonate or poly adj pheynyleneether or polysulfone or polyethersulfone or polyacrylater or polyalylate or polyamide-imide or resin or polyester or polyurethane)) same (resist or pr or photoresist) near4 reflow\$4	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/16 20:22
13	57	((polyacrylic or polyvinyl or polyvinylacetal or polyvinylalcohol or polyethyleneimine or polyethyleneoxide or styrene near2 maleic or methylvinyleher or polyallylamine) or (polyimide or polyacetal or polybutylene adj terephthalate or polyethylne adj trephthalate or syndiotactic adj polystyree or (polyphenylene or poly adj phenylene) adj slufide or polyetherether adj ketone or crystal adj polymer or fluorine adj resin or polyehtermitrile or polycarbonate or poly adj pheynyleneether or polysulfone or polyethersulfone or polyacrylater or polyalylate or polyamide-imide or resin or polyester or polyurethane)) same (resist or pr or photoresist) near4 reflow\$4	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/16 20:23
14	44	((polyacrylic or polyvinyl or polyvinylacetal or polyvinylalcohol or polyethyleneimine or polyethyleneoxide or styrene near2 maleic or methylvinyleher or polyallylamine) or (polyimide or polyacetal or polybutylene adj terephthalate or polyethylne adj trephthalate or syndiotactic adj polystyree or (polyphenylene or poly adj phenylene) adj slufide or polyetherether adj ketone or crystal adj polymer or fluorine adj resin or polyehtermitrile or polycarbonate or poly adj pheynyleneether or polysulfone or polyethersulfone or polyacrylater or polyalylate or polyamide-imide or resin or polyester or polyurethane)) same (resist or pr or photoresist) near4 reflow\$4	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/16 21:48
15	238	edge near2 rough\$6 near2 (resist or pr or photoresist) near4 reflow\$4 and (@ad < "20020826")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/16 20:40
16	1	(edge near2 rough\$6 near2 (resist or pr or photoresist)) same reflow\$4	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/16 20:41
17	2	(edge near2 rough\$6 near2 (resist or pr or photoresist)) and ((resist or pr or photoresist) near2 reflow\$4)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/16 21:04
18	409	hasegawa-norio.in.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/16 21:05
19	0	katsuya-hayano.in.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/16 21:05
20	785284	hitachi.as.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/16 21:05
21	277	hasegawa-norio.in. and hitachi.as.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/16 21:05

22	207841	(resist or pr or photoresist).ab.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/16 21:06
23	116	(hasegawa-norio.in. and hitachi.as.) and ((resist or pr or photoresist).ab.)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/16 21:06
24	0	05192151.pran.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/16 21:06
25	0	5192151.pran.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/16 21:40
26	2	20040038549.pn.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/16 21:40
27	1	20040038549.pn. and metal	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/16 21:40
28	1	20040038549.pn. and metal near4 film	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/16 21:40
29	512840	throughhole or through adj hole or viahole or via adj hole	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/16 21:45
30	441	organic\$4 near2 antireflect\$4	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/16 21:47
31	1869961	oxide or nitride or insulator or dielectric	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/16 21:47
32	14	(oxide or nitride or insulator or dielectric) same (organic\$4 near2 antireflect\$4) near8 pattern\$4 near4 (resist or pr or photoresist)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/16 21:48
33	14	((oxide or nitride or insulator or dielectric) same (organic\$4 near2 antireflect\$4) near8 pattern\$4 near4 (resist or pr or photoresist)) and (@ad < "20020826")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/16 22:02
34	766	(metal) adj2 (over or top or cover\$4) adj2 (resist or pr or photoresist)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/16 22:02

35	13	((metal) adj2 (over or top or cover\$4) adj2 (resist or pr or photoresist)) and ((resist or pr or photoresist) near2 reflow\$4)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/16 22:02
36	12	(((metal) adj2 (over or top or cover\$4) adj2 (resist or pr or photoresist)) and ((resist or pr or photoresist) near2 reflow\$4)) and (@ad < "20020826")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/16 22:02
37	4682	((438/551) or (438/694) or (438/725) or (438/945)).CCLS.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/16 22:10